

# Cypress Semiconductor Qualification Report

QTP# 97517 VERSION 1.0  
August, 1998

<b>1/2 Meg SRAM, R42D Technology, Fab 4 Qualification</b>	
CY7C1020V/CY7C1022V	32K x 16 Static RAM

CYPRESS TECHNICAL CONTACT FOR QUALIFICATION DATA:

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PRODUCT DESCRIPTION (for qualification)	
Information provided in this document is intended for generic qualification and technically describes the Cypress part supplied:	
Marketing Part #:	CY7C1020V/CY7C1022V
Package:	44-pin TSOP Type II
Device Description:	½ MegSRAM, R42D Technology
Cypress Division:	Cypress Semiconductor Corporation – MPD Division
Overall Die (or Mask) REV Level (pre-requisite for qualification):	Rev. B
What ID markings on Die:	7C1320B/7C1322B

TECHNOLOGY/FAB PROCESS DESCRIPTION - R42D			
Number of Metal Layers:	2	Metal Composition:	Metal 1: TiW,AlCu,TiW/500Å,6000Å,1200Å Metal 2: TiW,AlCu,TiW/500Å,8000Å,300Å
Passivation Type and Materials:	3000Å SiO <sub>2</sub> + 6000Å Si <sub>3</sub> N <sub>4</sub>		
Free Phosphorus contents in top glass layer(%):	0%		
Die Coating(s), if used:	N/A		
Generic Process Technology/Design Rule (μ-drawn):	CMOS, Double Metal /0.35 μm		
Gate Oxide Material/Thickness (MOS):	SiO <sub>2</sub> / 70 Å		
Name/Location of Die Fab (prime) Facility:	Cypress Semiconductor - Bloomington, MN		
Die Fab Line ID/Wafer Process ID:	Fab4/R42D		

PLASTIC PACKAGE/ASSEMBLY DESCRIPTION			
Package Outline, Type, or Name:	44-pins TSOP Type II		
Mold Compound Name/Manufacturer:	Sumitomo7320		
Lead Frame material:	Copper Alloy 194		
Lead Finish, composition:	Solder Plated, 90%Sn, 10%Pb		
Die Attach Area Plating:	Silver Spot		
Die Attach Method:	Epoxy	Die Attach Material:	Ablestik 8361H
Wire Bond Method:	Thermosonic	Wire Material/Size:	Gold / 1.3 mil
JESD22-A112 Moisture Sensitivity Level:	Level 3		
Name/Location of Assembly (prime) facility:	Huyn dai, Korea (KOREA-H)		

**Note:** Please contact a Cypress Representative for other packages availability.

**RELIABILITY TESTS PERFORMED**

Stress/Test	Test Condition (Temp/Bias)	Result P/F
High Temperature Operating Life Early Failure Rate	Dynamic Operating Condition, Vcc = 3.8 V, 125°C	P
High Temperature Operating Life Latent Failure Rate	Dynamic Operating Condition, Vcc = 3.8 V, 125°C	P
Temperature Cycle	MIL-STD-883C, Method 1010, Condition C, -65°C to 150°C Precondition: JESD22 Moisture Sensitivity Level 3 (192 Hrs, 30C/60%RH)	P
Acoustic Microscopy	Cypress Spec 25-000104	P
Electrostatic Discharge Human Body Model (ESD-HBM)	MIL-STD-883, Method 3015.7	2,200V
Electrostatic Discharge Charge Device Model (ESD-CDM)	Cypress Spec. 25-00020	1000V
Latchup Sensitivity Static Latchup	In accordance with JEDEC 17. Cypress Spec. 01-00081	8.3V

**RELIABILITY FAILURE RATE SUMMARY**

Stress/Test	Device Tested/ Device Hours	# Fails	Activation Energy	Thermal AF <sup>4</sup>	Failure Rate
High Temperature Operating Life Early Failure Rate <sup>1</sup>	3012 devices (4 Meg SRAM, R42D, Qtp #97396)	1	N/A	N/A	332 PPM
	1500 devices (1/2 Meg SRAM, R42D, Qtp #97517)	0	N/A	N/A	0 PPM
High Temperature Operating Life <sup>2,3</sup> Long Term Failure Rate	341,500 DHRs (4 Meg SRAM, R42D, Qtp #97396)	0	0.7	170	16 FIT
	258,192 DHRs (1/2 Meg SRAM, R42D, Qtp #97517)	0	0.7	55	64 FIT

<sup>1</sup> A production burn-in of 24 Hrs at 150°C, 4.3V is required for the product.

<sup>2</sup> Assuming an ambient temperature of 55°C and a junction temperature rise of 15°C.

<sup>3</sup> Chi-squared 60% estimations used to calculate the failure rate.

<sup>4</sup> Thermal Acceleration Factor is calculated from the Arrhenius equation

$$AF = \exp \left[ \frac{E_A}{k} \left[ \frac{1}{T_2} - \frac{1}{T_1} \right] \right]$$

where:

E<sub>A</sub> = The Activation Energy of the defect mechanism.

k = Boltzmann's constant = 8.62x10<sup>-5</sup> eV/Kelvin.

T<sub>1</sub> is the junction temperature of the device under stress and T<sub>2</sub> is the junction temperature of the device at use conditions.

RELIABILITY TEST DATA

QTP#: 97517

DEVIDE	ASSY-LOC	FABLOT#	ASSYLOT#	DURATION	S/S	REJ	FAIL MODE
<b>STRESS: HIGH TEMP DYNAMIC OPERATING LIFE-EARLY FAILURE RATE (125C, 3.8V)</b>							
CY7C1020V33-ZSC	KOREA-H	4801568	619802538/9/40L	96	1500	0	
<b>STRESS: ESD-CHARGE DEVICE MODEL (1000V)</b>							
CY7C1020V33-ZSC	KOREA-H	4801568	619802538/9/40L	COMP	3	0	
<b>STRESS: ESD-HUMAN BODY CIRCUIT PER MIL STD 883, METHOD 3015 (2000V)</b>							
CY7C1020V33-ZSC	KOREA-H	4801568	619802538/9/40L	COMP	3	0	
<b>STRESS: HIGH TEMP DYNAMIC OPERATING LIFE-LATENT FAILURE RATE (125C, 3.8V)</b>							
CY7C1020V33-ZSC	KOREA-H	4801568	619802538/9/40L	168	261	0	
CY7C1020V33-ZSC	KOREA-H	4801568	619802538/9/40L	2000	117	0	
<b>STRESS: TC COND. C, -65 TO 150C, PRECOND. 192 HRS 30C/60%RH (MSL 3)</b>							
CY7C1020V33-ZSC	KOREA-H	4801568	619802538/9/40L	300	48	0	

DEVICE RELATED RELIABILITY TEST DATA

QTP#: 97396<sup>1</sup>

DEVICE	ASSY-LOC	FABLOT#	ASSYLOT#	DURATION	S/S	REJ	FAIL MODE
<b>STRESS: HIGH TEMP DYNAMIC OPERATING LIFE-EARLY FAILURE RATE (150C, 3.8V)</b>							
CY7C1049V33-VC	KOREA-L	4744980	619711941	48	217	0	
CY7C1049V33-VC	KOREA-L	4743899	619711944	48	410	1	1 METAL DEFECT
CY7C1049V33-VC	KOREA-L	4745051	619800475	48	756	0	
CY7C1049V33-VC	KOREA-L	4744957	619800476	48	443	0	
CY7C1049V33-VC	KOREA-L	4741412	619801943	48	1186	0	1 EOS
<b>STRESS: ESD-CHARGE DEVICE MODEL (1000V)</b>							
CY7C1049V33-VC	KOREA-L	4743899	619711944	COMP	3	0	
CY7C1041V33-VC	CSPI-R	4751412	619801712	COMP	3	0	
<b>STRESS: ESD-HUMAN BODY CIRCUIT PER MIL STD 883, METHOD 3015 (4,400V)</b>							
CY7C1049V33-VC	KOREA-L	4744957	619800476	COMP	3	0	
CY7C1041V33-VC	CSPI-R	4751412	619801712	COMP	3	0	
<b>STRESS: HI-ACCEL SATURATION TEST (140C, 3.63V), PRECOND. 192 HRS 30C/60%RH</b>							
CY7C1049V33-VC	KOREA-L	4743899	619711944	128	45	0	
<b>STRESS: HIGH TEMP STEADY STATE LIFE TEST (150C, 3.63V)</b>							
CY7C1049V33-VC	KOREA-L	4745051	619800475	80	76	0	
CY7C1049V33-VC	KOREA-L	4745051	619800475	168	76	0	
CY7C1049V33-VC	KOREA-L	4744957	619800476	80	75	0	1 EOS
CY7C1049V33-VC	KOREA-L	4744957	619800476	168	74	0	
<b>STRESS: HIGH TEMP DYNAMIC OPERATING LIFE-LATENT FAILURE RATE (150C, 3.8V)</b>							
CY7C1049V33-VC	KOREA-L	4745051	619800475	80	380	0	
CY7C1049V33-VC	KOREA-L	4745051	619800475	500	379	0	1 EOS
CY7C1049V33-VC	KOREA-L	4744957	619800476	80	304	0	
CY7C1049V33-VC	KOREA-L	4744957	619800476	500	304	0	
<b>STRESS: COLD LIFE TEST (-30C, 4.3V)</b>							
CY7C1049V33-VC	KOREA-L	4743899	619711944	500	41	0	
CY7C1049V33-VC	KOREA-L	4743899	619711944	1000	41	0	
<b>STRESS: READ &amp; RECORD LIFE TEST (150C, 3.8V)</b>							
CY7C1049V33-VC	KOREA-L	4743899	619711944	80	10	0	
CY7C1049V33-VC	KOREA-L	4743899	619711944	500	10	0	
<b>STRESS: TC COND. C, -65 TO 150C, PRECOND. 192 HRS 30C/60%RH (MSL 3)</b>							
CY7C1049V33-VC	KOREA-L	4743899	619711944	300	45	0	
CY7C1049V33-VC	KOREA-L	4743899	619711944	1000	45	0	
CY7C1049V33-VC	KOREA-L	4745051	619800475	300	45	0	
CY7C1049V33-VC	KOREA-L	4745051	619800475	1000	45	0	
CY7C1049V33-VC	KOREA-L	4744957	619800476	300	45	0	
CY7C1049V33-VC	KOREA-L	4744957	619800476	1000	45	0	

<sup>1</sup> 4 Meg SRAM, R42D Technology, Fab 4 qualification